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**Mr. Sarohan Park**

(Advanced Photo, SK Hynix, Korea)



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Mr. Sarohan Park received his MS degree in ceramic engineering from the Yonsei University (Korea) in 2003. He has been developing the advanced photo process technology such as ArF immersion and EUV process at SK Hynix R&D since 2003. In 2011, he had joined the advanced lithography program of IMEC (Belgium) as SK Hynix assignee and researched the EUV stochastic effect of C/H patterning for two and a half years. Recently, He had developed the photo process of DRAM 1a node that adopted the EUV process. Now, he is the head of Advanced Photo team at R&D and in charge of the development for next generation lithography.